# Adsorption Sites on Pd/AI<sub>2</sub>O<sub>3</sub>

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On a Pd/Al<sub>2</sub>O<sub>3</sub> catalyst, CO and H<sub>2</sub> interact to form CH<sub>3</sub>O on the Al<sub>2</sub>O<sub>3</sub> support. This CH<sub>3</sub>O hydrogenates to CH<sub>4</sub> at a faster rate than the CO adsorbed on Pd. At high CH<sub>3</sub>O coverages, CH<sub>3</sub>O decomposition competes with hydrogenation. The effects of  $H_2$  pressure and adsorption temperature on the rate of CH<sub>3</sub>O formation were measured. Isotope studies show that CO adsorbs on Pd and then spills over onto  $A<sub>1</sub>, O<sub>3</sub>$  where CH<sub>3</sub>O is more readily hydrogenated to CH<sub>4</sub>. The higher methanation activity of CH<sub>3</sub>O than of CO on Pd may be responsible for the much higher, steady-state methanation activity observed for  $Pd/A1_2O_3$  than for  $Pd/SiO_2$  catalysts. © 1991 Academic Press, Inc.

#### INTRODUCTION

When CO and  $H_2$  coadsorb on  $Al_2O_3$ - and  $TiO<sub>2</sub>$ -supported metals (Ni, Ru, Pt) at elevated temperatures,  $CO$  and  $H<sub>2</sub>$  adsorb directly on the metal and also form a  $CH<sub>x</sub>O$ species on the support by spillover. Temperature-programmed reaction (TPR) has shown that these two adsorbed species hydrogenate to  $CH<sub>4</sub>$  at different rates. On Ni/ Al<sub>2</sub>O<sub>3</sub> (1–4), Ni/TiO<sub>2</sub> (5), and Ru/Al<sub>2</sub>O<sub>3</sub> (6) catalysts, CO adsorbed on the metal is hydrogenated to  $CH<sub>4</sub>$  faster than CH<sub>x</sub>O is hydrogenated. In contrast, on  $Pt/Al_2O_3$  (7, 8) and  $Pt/TiO<sub>2</sub>(9)$  catalysts, the CH<sub>x</sub>O species is hydrogenated faster than CO adsorbed on Pt. On  $Pt/Al_2O_3$  (7), the CH<sub>r</sub>O species was shown by infrared spectroscopy to be methoxy  $(CH_3O)$ . On all these catalysts, the stoichiometry of CH<sub>x</sub>O, as measured by temperature-programmed desorption (TPD), was close to that of a  $CH<sub>3</sub>O$  species. The Ni, Ru, and Pt catalysts exhibit different behaviors because Pt is a poor methanation catalyst, but Ni and Ru are active methanation catalysts.

On  $Pd/SiO<sub>2</sub>$  and unsupported Pd catalysts, steady-state methanation activity is low, but the activity of  $Pd/Al_2O_3$  is 70-fold greater than unsupported Pd and 35 times that of  $Pd/SiO<sub>2</sub>(10)$ . Thus, the specific activities of  $Pd/Al_2O_3$  catalysts were only a factor of three less than those of typical Ni methanation catalysts *(10).* 

Since infrared spectroscopy has observed a CH<sub>3</sub>O species adsorbed on the support of  $Pd/Al_2O_3$ , but not on  $Pd/SiO_2$  upon exposure to  $H_2/CO$  mixtures (11), hydrogenation of  $CH<sub>3</sub>O$  may be responsible for the higher methanation activity of  $Pd/Al_2O_3$ . On Ni catalysts, CO dissociates at relatively low temperatures and thus Ni is an active methanation catalyst. In contrast, CO does not dissociate as readily on Pd *(11),* and CO dissociation to carbon and oxygen may not be the pathway followed to form  $CH<sub>4</sub>$  on Pd. The objective of the present study was to measure the rate of  $CH<sub>3</sub>O$  formation and hydrogenation on  $Pd/Al_2O_3$ . Temperatureprogrammed reaction was used to measure the hydrogenation rate, and TPD was used to determine if CH<sub>3</sub>O was present on the Pd/  $Al_2O_3$  catalyst. TPD and TPR have only been used previously in a few studies to characterize supported Pd catalysts  $(12-16)$ .

A Pd/Al<sub>2</sub>O<sub>3</sub> catalyst might be expected to behave differently from supported Pt catalysts, however, since Pd is a selective methanol synthesis catalyst at higher pressures *(17)*, and thus CH<sub>3</sub>O might be expected to form more readily on the Pd surface. Since methanol forms only at higher pressures *(10, 17),* coadsorption was also carried out in 2.6 atm  $H<sub>2</sub>$  pressure in some experiments to try to increase the yield of methanol or methoxy.

### EXPERIMENTAL METHODS

Temperature-programmed desorption (TPD) and reaction (TPR) experiments were carried out on a 3.7%  $Pd/Al_2O_3$  catalyst in a modified version of an apparatus that was described previously *(1, 18).* A quartz frit, mounted in a 1-cm OD quartz downflow reactor, supported 100 mg of catalyst (60-80 mesh). The reactor was placed in an electric furnace with a 0.5-mm OD chromel-alumel shielded thermocouple centered in the catalyst bed. A temperature programmer used feedback from this thermocouple to raise the catalyst temperature from 300 to 773 K at a constant rate of 1 K/s. Immediately downstream from the reactor, the effluent gas was continuously analyzed by a UTI quadrupole mass spectrometer. A sampling valve interfaced the ambient-pressure gas stream to the ultrahigh vacuum system, which contained the mass spectrometer and was pumped by a turbomolecular pump. A computer allowed simultaneous observation of multiple masses and the thermocouple signal. For the TPD experiments, masses 2 (H<sub>2</sub>), 15 (CH<sub>3</sub>), 18 (H<sub>2</sub>O), 28 (CO), and  $44$  (CO<sub>2</sub>) were monitored. Methane was observed at mass 15 to avoid  $CO$ ,  $CO<sub>2</sub>$ , and H<sub>2</sub>O cracking fractions at mass 16. In the TPR experiments, masses 15, 18, 28, 31  $(CH<sub>3</sub>O)$ , 44, 45  $(CH<sub>3</sub>OCH<sub>3</sub>)$ , and 46  $(CH<sub>3</sub>OCH<sub>3</sub>)$  were monitored. Mass 31 is the largest cracking fragment of CH<sub>3</sub>OH. The mass 28 and 31 signals were corrected for  $CO<sub>2</sub>$  and  $CH<sub>3</sub>OCH<sub>3</sub>$  cracking, respectively. Known volumes of pure gas or liquid were injected into the carrier gas, downstream of the reactor, to calibrate the mass spectrometer.

At the beginning of each series of experiments, the reduced catalyst was pretreated for 2 h at 773 K in ambient pressure  $H_2$  flow. To maintain a clean surface, the catalyst was treated in  $H<sub>2</sub>$  at 773 K for 15 min after each TPR experiment. Carbon monoxide was adsorbed on the catalyst by using a pulse valve, which injected  $0.15 \text{ cm}^3$  (STP) samples of 10% CO/90% He into the carrier gas twice a minute.

For TPD experiments, the catalyst was cooled in  $H_2$  flow, and CO was adsorbed at  $385$  K in H<sub>2</sub> flow at either ambient pressure or 2.6 atm. The catalyst was then cooled to 300 K, the carrier gas switched to He, and TPD carried out by raising the catalyst temperature at 1 K/s in He flow.

For most TPR experiments, the catalyst was cooled in  $H_2$  flow from 773 K, and CO was adsorbed at 385 K. In afew experiments the catalyst was cooled from 773 K in He flow, and CO was adsorbed at 300 K in He. The adsorption time was varied for two series of experiments at 385 K; ambient pressure  $H<sub>2</sub>$  was used during one adsorption series and  $H<sub>2</sub>$  at 2.6 atm was used for the other series. In some cases CO was adsorbed in Hz/He mixtures. Separate mass flow controllers were used for  $H<sub>2</sub>$  and He to obtain these mixtures. A back pressure regulator was used to control the total pressure of the reaction system above ambient. For some TPR experiments, the catalyst was exposed to pulses of  $100\%$  <sup>13</sup>CO for 15 min or 20 min at  $300$  K after <sup>12</sup>CO adsorption in H<sub>2</sub> at 385 K. Masses 15, 17 ( ${}^{13}CH_4$ ), 28, 29( ${}^{13}CO$ ), 31,  $32(^{13}CH_3O)$ , 44, 45, 46, and 47 ( $^{13}CH_3OCH_3$ ) were monitored during the subsequent TPR experiment. To obtain the  ${}^{13}CH_4$  spectra, the mass 17 signal was corrected for cracking of  $H_2O$ . The TPR experiments were carried out by raising the catalyst temperature at a rate of 1 K/s in *ambient pressure* H<sub>2</sub> flow, regardless of the adsorption pressure.

The procedure used to prepare the Pd/  $Al_2O_3$  catalyst was adapted from Palazov *et al. (11).* Kaiser A-201 alumina (60 to 80 mesh) was impregnated to incipient wetness with aqueous  $PdCl<sub>2</sub>$ . The impregnated alumina was air-dried for 24 h and then dried in vacuum for 24 h at 373-383 K. The catalyst was then calcined for 10 min at 573 K with 2%  $O_2$  in  $N_2$ , reduced in  $H_2$  at 573 K

for 5 h, and finally passivated with  $2\%$  O<sub>2</sub> in  $N<sub>2</sub>$  at room temperature. This catalyst had a weight loading of 3.7% Pd, as measured by ICP-MS. Because this catalyst showed signs of incomplete reduction during preliminary experiments, it was further reduced for 5 h at 773 K.

Miura *et al. (19)* reported that chlorine has little or no effect on the chemisorption capacity or the propane hydrogenolysis rate for Pd/Al<sub>2</sub>O<sub>3</sub> catalysts reduced at 600 K. They concluded that most of the chlorine remaining from the catalyst preparation was associated with the support, not the Pd. Since our studies involve CH<sub>3</sub>O adsorbed on the support, this chlorine might be expected to affect CH<sub>3</sub>O adsorption, but the CH<sub>3</sub>O amounts we observe are similar to those seen on  $Ni/Al<sub>2</sub>O<sub>3</sub>$  catalysts that do not contain chlorine.

#### RESULTS AND DISCUSSION

## *Identification of CH<sub>x</sub>O Species</sub>*

As observed previously for Ni, Ru, and Pt supported on  $\text{Al}_2\text{O}_3$  (6, 8, 20), when CO was adsorbed for 30 min on  $Pd/Al_2O_3$ , more CO adsorbed at 385 K in H<sub>2</sub> flow than at 300 K in He flow. This increase in adsorption amount is not likely to be due to carbon deposition at 385 K; several studies have reported that CO does not dissociate to a significant extent below 475 K on Pd *(11,*  17), and CO desorbs from Pd/Al<sub>2</sub>O<sub>3</sub> with very little CO<sub>2</sub> formation. Ichikawa et al. *(21)* reported that CO disproportionated on highly-dispersed  $Pd/SiO<sub>2</sub>$  catalysts, but for a lower dispersion of 45%, CO did not disproportionate. Thus, significant carbon deposition is not expected on our catalysts.

After CO adsorption at 385 K in  $H_2$  flow,  $H<sub>2</sub>$  and CO desorbed simultaneously, with a peak maximum at 495 K, during a subsequent TPD. The  $H_2$  and CO desorption peaks were quite different from those observed when  $H_2$  and CO were adsorbed individually on this catalyst or other  $Pd/Al_2O_3$ catalysts *(14, 15).* Because of these differences and because  $H_2$  and CO desorbed simultaneously, their formation during TPD



FIG. 1. Hydrogen TPD spectra following CO and H<sub>2</sub> coadsorption at 385 K on 3.7% Pd/Al<sub>2</sub>O<sub>3</sub>. The H<sub>2</sub> carrier gas was at 2.6 atm and CO pulses were injected for (a) 15 min, (b) 30 min, (c) 60 min.

was concluded to be limited by decomposition of a  $CH<sub>x</sub>O$  surface species. The  $H/CO$ ratio was 3.8. The similarity of the TPD results to previous TPD studies on other AlzO3-supported metals *(6, 8, 20),* and the detection of  $CH<sub>3</sub>O$  on  $Pd/Al<sub>2</sub>O<sub>3</sub>$  by infrared spectroscopy  $(11)$  indicates that  $CH<sub>3</sub>O$  may be present on our  $Pd/Al_2O_3$  catalyst. The CH<sub>3</sub>O is most likely adsorbed on the  $Al_2O_3$ surface, since studies with mixtures of  $\text{Al}_2\text{O}_3$ and Pt/Al<sub>2</sub>O<sub>3</sub> (8) and Al<sub>2</sub>O<sub>3</sub> and Ni/Al<sub>2</sub>O<sub>3</sub>  $(22)$  show that CH<sub>3</sub>O is on the Al<sub>2</sub>O<sub>3</sub>. The infrared studies by Palozov *et al. (11)* also concluded that  $CH<sub>3</sub>O$  was on the Al<sub>2</sub>O<sub>3</sub> support. They concluded CH<sub>3</sub>O formed on Pd and was subsequently transferred to  $AI<sub>2</sub>O<sub>3</sub>$ by spillover *(11).* An exact measure of the stoichiometry of the adsorbed  $CH<sub>x</sub>O$  species cannot be determined from the TPD amounts because  $H<sub>2</sub>$  and CO are also adsorbed on the Pd surface. Small amounts of  $CH<sub>4</sub>$  and  $CO<sub>2</sub>$  (less than 2% of the CO amount) were also observed during TPD of coadsorbed CO and  $H_2$ , but no CH<sub>3</sub>OH desorbed.

Temperature-programmed desorption was also carried out following CO adsorption in 2.6 atm  $H_2$  for various times. As observed for CO adsorption in  $H<sub>2</sub>$  flow at ambient pressure, CO and  $H<sub>2</sub>$  desorbed simultaneously, with a peak maximum at 495 K (Figs. 1 and 2). Figures  $1(a)$  and  $2(a)$  (CO)



FIG. 2. Carbon monoxide TPD spectra following CO and H<sub>2</sub> coadsorption on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub>. Same conditions as Fig. 1.

adsorption for 15 min in 2.6 atm  $H_2$ ) are almost identical to the  $H<sub>2</sub>$  and CO spectra observed following CO adsorption in ambient pressure  $H_2$  for 30 min. The stoichiometry of the  $CH<sub>x</sub>O$  species was estimated from the H/CO ratio, which was 3.3 when the  $CH<sub>4</sub>$  and  $CO<sub>2</sub>$  amounts were taken into account. The H/CO ratio of the amplitudes of the TPD peaks at 495 K was 4.5. When the CO adsorption time was increased from 15 to 30 min in 2.6 atm  $H_2$ , the  $H_2$  and CO desorption amounts increased significantly (Figs. l(b) and 2(b)), and the H/CO ratio increased to 3.6. When CO exposure in 2.6 atm  $H<sub>2</sub>$  was increased from 30 to 60 min, the amount of adsorbed CO only increased by 15%; the surface was close to saturation after 60 min exposure. The H/CO ratio was 3.8. These stoichiometric values are consistent with the formation of CH<sub>3</sub>O, which has been observed by infrared spectroscopy. However, some CH<sub>3</sub>OH and CH<sub>3</sub>OCH<sub>3</sub> may also have formed, particularly at the higher exposures. For convenience we will refer to the  $CH<sub>x</sub>O$  species as  $CH<sub>3</sub>O$ .

During TPD, CH<sub>4</sub> formed in two distinct peaks, as shown in Fig. 3. The amount of  $CH<sub>4</sub>$  is small; note the scale difference beteen Figs. 2 and 3. The site responsible for the high-temperature  $CH<sub>4</sub>$  peak appears to saturate first, at low exposures. Small amounts of  $CO<sub>2</sub>$  were also observed. Desorption of methanol and dimethyl ether



FIG. 3. Methane TPD spectra following CO and  $H_2$ coadsorption on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub>. Same conditions as Fig. 1.

during TPD was only detected in trace amounts following the 60-min adsorption experiment. Thus, the  $CH<sub>3</sub>O$  species readily decomposed to mostly CO and  $H<sub>2</sub>$ .

## *Hydrogenation of Adsorbed Carbon Monoxide*

To compare  $CO$  and  $CH<sub>3</sub>O$  hydrogenation, CO was first adsorbed at 300 K in He flow, since this should ensure that initially the CO is present only on the Pd surface. Subsequent hydrogenation of this adsorbed CO yielded almost exclusively  $CH<sub>4</sub>$ , in what appears to be two overlapping peaks, as shown in Fig. 4(a). The overall peak maxi-



FIG. 4. Methane TPR spectra on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub>. Carbon monoxide adsorption conditions (a) He flow, 30 min at 300 K; (b) ambient pressure  $H_2$  flow, 30 min at 385 K; (c) ambient pressure H<sub>2</sub> flow, 60 min at 385 K. Note that the curves are displaced vertically for clarity.



FIG. 5. TPR spectra of unreacted CO on 3.7% Pd/  $Al_2O_3$ . Same conditions as Fig. 4.

mum was at 545 K, and reaction was complete by 600 K. Most of the unreacted CO  $(5\% \text{ of the CH}_4 \text{ amount})$  desorbed below 450 K, as shown in Fig. 5(a). When the catalyst was cooled in  $H_2$ , flow from 773 K and CO was adsorbed in  $H<sub>2</sub>$  at 300 K, the CH<sub>4</sub> and CO TPR spectra were the same as those in Fig. 4(a) and 5(b), respectively. Since the CO essentially adsorbed only on the Pd surface at 300 K in He flow, the CH<sub>4</sub> + CO amounts formed during TPR were used to estimate a Pd dispersion of 20%. This is a good estimate of dispersion because in other studies good agreement was obtained between TPR and  $H_2-O_2$  titration on a Pd/SiO<sub>2</sub> catalyst *(12).* 

Though the CO was adsorbed on Pd at  $300$  K in He, CH<sub>3</sub>O or its precursor spills over onto the  $Al_2O_3$  during TPR to form adsorbed CH<sub>3</sub>O. This spillover process was identified on  $Ni/Al<sub>2</sub>O<sub>3</sub>$  and  $Ni/TiO<sub>2</sub>$  catalysts by isotope labeling, and similar experiments on  $Pd/AI_2O_3$  are presented in a later section of this paper. Two distinct  $CH<sub>4</sub>$  peaks due to CH<sub>3</sub>O and CO hydrogenation could not be identified on  $Pd/Al_2O_3$ , however. The heating rate was decreased from 1.0 K/s to 0.1 K/s in an attempt to distinguish two distinct  $CH<sub>4</sub>$  peaks, but this approach was not successful. The shape of the  $CH<sub>4</sub>$  spectrum did not change at the lower heating rate; the methanation rate decreased by a factor of 10 and the main  $CH<sub>4</sub>$  peak shifted to 492 K.

To study CH<sub>3</sub>O hydrogenation, CO and  $H<sub>2</sub>$  were coadsorbed at 385 K since TPD experiments showed that this procedure produced CH<sub>3</sub>O. Three times more CO adsorbed on Pd/Al<sub>2</sub>O<sub>3</sub> at 385 K in H<sub>2</sub> than at 300 K in He. However, in contrast to Ni/  $Al_2O_3$  catalysts, only half of this adsorbed  $CO$  (present as  $CH<sub>3</sub>O$  and  $CO$ ) was hydrogenated to  $CH<sub>4</sub>$ . The other half desorbed as CO, as shown in Fig. 5(b). The amount of  $CH<sub>4</sub>$  formed (Fig. 4(b)) approximately doubled upon adsorption at 385 K, and the  $CH<sub>4</sub>$ peak temperature increased by 25 K. Methane formed in a broad peak, and the methanation rate below 500 K is *lower* for Fig. 4(b) than for Fig. 4(a). That is, at the higher coverage, the rate of methanation is lower than at a lower initial coverage. The higher coverage of CH<sub>3</sub>O appears to inhibit  $CH<sub>4</sub>$ formation, perhaps by inhibiting CO spillover from Pd to  $Al_2O_3$ . Thus, fewer Pd sites are available for  $H_2$  adsorption at the lower temperature in Fig. 4(b) because CO remains on Pd. For longer CO exposure times, the amount of  $CH<sub>4</sub>$  formed during TPR did not increase (Fig. 4(c) is essentially identical to Fig. 4(b), but the amount of unreacted CO increased (Fig. 5(c) is larger than Fig. 5(b). At the higher exposures, small amounts of  $CH<sub>3</sub>OH$  and  $CH<sub>3</sub>OCH<sub>3</sub>$  also formed during TPR, as might be expected for high  $CH<sub>3</sub>O$  coverages.

A comparison of Figs. 2 and 5 shows that CO desorbed with a 38 K higher peak temperature during TPR than during TPD. Carbon monoxide started forming at 400 K during TPD, but the rate of CO formation during TPR was only significant above 475 K. Thus, the CO desorption peaks during TPR were much narrower than those during TPD. Similarly,  $CH<sub>4</sub>$  formed with a 73 K higher peak temperature during TPR (Fig. 4(b),(c) than CO did during TPD. That is, for the same initial coverages, the presence of gas phase  $H_2$  significantly delayed CO desorption, most likely by inhibiting  $CH<sub>3</sub>O$ decomposition.

The high steady-state methanation activity of  $Pd/Al_2O_3$ , relative to  $Pd/SiO_2$  or unsupported Pd, may result because  $CH<sub>3</sub>O$  on  $Pd/Al_2O_3$  is hydrogenated faster than CO on Pd. For CO adsorbed at 300 K on  $Pd/Al_2O_3$ , some of the CO was hydrogenated to  $CH<sub>4</sub>$ during TPR starting at 450 K, with a shoulder below 500 K. The peak temperature was 545 K, and 95% of the adsorbed CO was hydrogenated to  $CH<sub>4</sub>$ . On Pd/SiO<sub>2</sub>, Rieck and Bell (12) observed a CH<sub>4</sub> peak temperature of 635 K, and only 43% of the CO adsorbed at 300 K was hydrogenated to  $CH<sub>4</sub>$ . Thus, the TPR results are consistent with steady-state kinetics, where the rate of methanation has been reported to be 35 times higher on Pd/Al<sub>2</sub>O<sub>3</sub> than on Pd/SiO<sub>2</sub>  $(10)$ . As the CH<sub>3</sub>O coverage was increased by CO and H<sub>2</sub> adsorption at  $385$  K, the rate of methanation below 500 K decreased and the  $CH<sub>4</sub>$  peak temperature increased. Even under these conditions, however, the  $CH<sub>4</sub>$ peak temperature on  $Pd/Al_2O_3$  is much lower than that for  $Pd/SiO<sub>2</sub>$  (12).

#### *Effect of H<sub>2</sub> Pressure on Adsorption*

The increased coverage with adsorption temperature and exposure time observed during TPR experiments is consistent with the TPD experiments. Thus, at higher coverages much of the  $CH<sub>3</sub>O$  does not hydrogenate to  $CH<sub>4</sub>$  during TPR. To study this, CO was adsorbed at 385 K for 30 min in various H<sub>2</sub> partial pressures. Temperature-programmed reaction was then carried out in each case in ambient pressure  $H_2$ . For a 13fold change in  $H<sub>2</sub>$  pressure during adsorption (from 0.2 to 2.6 atm), the amount of  $CH<sub>4</sub>$ formed during TPR changed only slightly. Approximately 135  $\pm$  15  $\mu$ mol CH<sub>4</sub>/g catalyst formed in each case, and the  $CH<sub>4</sub>$  spectra were almost the same as the  $CH<sub>4</sub>$  spectrum in Fig. 4(b).

In contrast to the  $CH<sub>4</sub>$  amounts, the amount of unreacted CO increased significantly as the  $H<sub>2</sub>$  pressure increased, as shown in Fig. 6. For the same 13-fold change in  $H_2$  pressure during adsorption, the CO signal increased more than a factor of 3.2. The CO desorption spectra broadened on the low temperature side as the amount of



FIC. 6. Carbon monoxide TPR spectra on 3.7% Pd/  $Al_2O_3$ . The TPR was carried out in ambient pressure  $H<sub>2</sub>$  (0.82 atm) but CO was adsorbed for 30 min at 385 K at a  $H_2$  pressure of (a) 0.20 atm, (b) 0.41 atm, (c) 0.82 atm, (d) 2.6 atm.

unreacted CO increased. Carbon dioxide production, though small, also increased with  $H<sub>2</sub>$  adsorption pressure. Methanol and CH<sub>3</sub>OCH<sub>3</sub> were only observed following CO adsorption in 2.6 atm  $H_2$ .

The initial rate of spillover to form  $CH<sub>3</sub>O$ is rapid and does not exhibit much dependence on  $H<sub>2</sub>$  pressure. Apparently the concentration of surface hydrogen does not limit the formation of  $CH<sub>3</sub>O$  at low coverages. As the rate of CH<sub>3</sub>O formation decreases at high coverages, the hydrogen coverage starts to affect the rate and thus higher H<sub>2</sub> pressures increase the rate. Moreover, at low coverages, most of the  $CH<sub>3</sub>O$ is hydrogenated to  $CH<sub>4</sub>$  during TPR, but as the coverage increases the fraction of  $CH<sub>3</sub>O$ that is hydrogenated decreases significantly. These changes with coverage could be due to the formation of two types of  $CH<sub>3</sub>O$ , perhaps linear and bridged forms as observed by IR for  $CH<sub>3</sub>OH$  adsorption on Pd/ThO<sub>2</sub> (23). However, only one form of CH<sub>3</sub>O has been observed by IR on  $\text{Al}_2\text{O}_3$ , and no unreactive CH<sub>3</sub>O was detected on Ni/Al<sub>2</sub>O<sub>3</sub> (2). Thus, the relative rates of  $CH<sub>3</sub>O$  decomposition versus CH<sub>3</sub>O methanation may depend on the CO and  $H<sub>2</sub>$  coverages on Pd. As the  $CH<sub>3</sub>O$  coverage increases, the amount of hydrogen adsorbed on Pd decreases because of coadsorbed CO, and decomposi-



FIG. 7. Carbon monoxide TPR spectra on 3.7% Pd/  $AI<sub>2</sub>O<sub>3</sub>$ . The TPR was carried out in ambient pressure  $H<sub>2</sub>$ , but CO was adsorbed for 5 min at 385 K in a  $H<sub>2</sub>$ pressure of (a)  $0.20$  atm, (b)  $0.41$  atm, (c)  $0.82$  atm, (d) 2.6 atm. Note that the curves are displaced vertically for clarity.

tion competes effectively with methanation. Thus, some CH<sub>3</sub>O must decompose and the product CO desorb to obtain a lower coverage so that methanation can take place.

When the same series of adsorption and TPR experiments was carried out for 5 min of CO exposure at 385 K instead of 30 min, less  $CH<sub>4</sub>$  was observed during TPR than for 30 min of CO exposure, and the dependence on  $H<sub>2</sub>$  pressure during adsorption was still small. When  $0.2$  atm  $H<sub>2</sub>$  was used during adsorption, 69  $\mu$ mol CH<sub>4</sub>/g catalyst formed; for 2.6 atm, 85  $\mu$ mol CH<sub>4</sub>/g catalyst formed. At this lower CO exposure, the amount of unreacted CO observed during TPR was quite small, only 2–3  $\mu$ mol/g catalyst; the rate of  $CH<sub>3</sub>O$  formation is rapid at low coverages, and thus  $H_2$  pressure does not affect it much. As shown in Fig. 7, CO desorbed in three distinct peaks, and *less* CO desorbed as the  $H<sub>2</sub>$  pressure increased. The high temperature peak is also similar to CO desorption (carbon-oxygen recombination) observed for TPD following CO adsorption at 300 K.

#### *Surface Coverage Variation*

The changes in product amounts with CO exposure was studied in 2.6 atm  $H_2$  in order to saturate the surface with  $CH<sub>3</sub>O$  more rapidly, and adsorption times up to 90 min were used. Since  $CH<sub>3</sub>OH$  and  $CH<sub>3</sub>OCH<sub>3</sub>$  were only detected in significant amounts for CO adsorption in 2.6 atm  $H_2$ , these conditions also provided a means to obtain higher coverages of oxygenates.

Figure 8 shows the  $CH<sub>4</sub>$  and  $H<sub>2</sub>O$  spectra for three CO exposure times in 2.6 atm  $H_2$ at 385 K. Note that the  $CH<sub>4</sub>$  and  $H<sub>2</sub>O$  signals did not change much (Fig. 8(b),(c)) after the first 15 min of CO exposure (Fig. 8(a)). Note also that  $H<sub>2</sub>O$  did not appear in the gas phase until  $CH<sub>4</sub>$  formation was essentially complete. The  $H<sub>2</sub>O$  signals were not calibrated, but were presented on a scale consistent with the  $CH<sub>4</sub>$  signals. In one experiment, TPR was interrupted at 600 K, a temperature where essentially all the  $CH<sub>4</sub>$  and CO had left the surface but the  $H<sub>2</sub>O$  remained on the  $Al_2O_3$ . A subsequent TPR following CO adsorption at 300 K was the same as that in Figs.  $4(a)$  and  $5(a)$ . The H<sub>2</sub>O at this concentration on the  $Al<sub>2</sub>O<sub>3</sub>$  did not affect the reaction rate of CO that was originally adsorbed on Pd. The H<sub>2</sub>O, which forms as one of the products of the methanation reaction, apparently readsorbs on the  $Al_2O_3$  surface and thus desorbs at a higher temperature than  $CH_4$ . Studies on a Ni/SiO<sub>2</sub> catalyst



FIG. 8. Methane (solid lines) and water (dashed lines) TPR spectra on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub> following CO adsorption at 385 K in 2.6 atm  $H_2$ . Carbon monoxide exposure times: (a) 15 min, (b) 30 min, (c) 60 min. Note that the curves are displaced vertically for clarity.



FIG. 9. Carbon monoxide TPR spectra on 3.7% Pd/  $Al_2O_3$ . Same conditions as Fig. 8.

mixed with an  $Al_2O_3$  support showed that water from methanation, which formed at the same temperature as  $CH<sub>4</sub>$  on Ni/SiO<sub>2</sub>, was delayed to higher temperatures because of readsorption on  $Al_2O_3$  (24).

In contrast to the  $CH<sub>4</sub>$  and H<sub>2</sub>O signals, the amount of unreacted CO increased at longer exposure times, as shown in Fig. 9. The CH<sub>3</sub>OH and CH<sub>3</sub>OCH<sub>3</sub> products (Figs. l0 and 11) were barely detectable after 15 min exposure, but these signals exhibited dramatic increases at longer exposure times. A four-fold increase in exposure time increased the concentration of these desorbing oxygenates by 25-100 times. The oxygenate amounts are sensitive to  $H<sub>2</sub>$  pressure used during adsorption, even though the  $CH<sub>4</sub>$  amount is not. The amount of oxygenates obtained after 15 min of CO exposure at 385 K in 2.6 atm  $H<sub>2</sub>$  are almost identical to the amounts obtained after 60 min at 385 K at 0.8 atm  $H_2$ , as if the amount of oxygenates increases linearly with  $H_2$  pressure. The  $CH<sub>3</sub>OCH<sub>3</sub>$  signal had a lower peak temperature than CH<sub>3</sub>OH, and its formation was complete by 550 K, but  $CH<sub>3</sub>OH$  formed in two peaks up to 750 K. The  $CH<sub>3</sub>OH$  signal was corrected for the cracking fragment from  $CH<sub>3</sub>OCH<sub>3</sub>$ . The ratio of mass 45 to mass 46 signals was used to determine that the signal at mass 46 was from dimethyl ether and not formic acid or ethanol.

The formation of  $CH<sub>3</sub>OH$  during TPR is



FIG. 10. Methanol TPR spectra on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub>. Same conditions as Fig. 8. Note that the curves are displaced vertically for clarity.

consistent with the conclusion that  $CH<sub>3</sub>O$ forms on the  $Al_2O_3$  surface. Apparently most of the CH<sub>3</sub>O either decomposes to CO and  $H<sub>2</sub>$  or is hydrogenated completely to  $CH<sub>4</sub>$  during TPR. However, near saturation coverage the pathway to CH<sub>3</sub>OH desorption opens up. The  $CH<sub>3</sub>OCH<sub>3</sub>$  may form by CH<sub>3</sub>OH decomposition on  $Al_2O_3$  (25).

Figure 12 summarizes the amounts of products, observed during TPR, as a function of CO exposure time at 385 K in 2.6 atm  $H<sub>2</sub>$ . Zero time corresponds to the amounts of products seen for CO adsorption in He at 300 K for 30 min, where all adsorption is expected to be on the Pd surface initially. The total amount of CH<sub>3</sub>O adsorption on the  $Al_2O_3$  surface, estimated from the difference



FIG. 11. Dimethyl ether TPR spectra on 3.7% Pd/  $Al_2O_3$ . Same conditions as Fig. 8.



FIG. 12. Product distribution during TPR as a function of CO exposure time. The CO was adsorbed in 2.6 atm H, on  $3.7\%$  Pd/Al<sub>2</sub>O<sub>3</sub> at 385 K.

between the total carbon amounts for adsorption at 385 K for 90 min and 300 K for 30 min, is 360  $\mu$ mol/g Al<sub>2</sub>O<sub>3</sub>. This is the same value measured on  $Ni/Al<sub>2</sub>O<sub>3</sub>$  and on mixtures of  $Al_2O_3$  and  $Ni/Al_2O_3$  (22). Since the same  $Al_2O_3$  was used in both studies, the same saturation coverage of  $CH<sub>3</sub>O$  might be expected to form. Apparently the chlorine that remained on the surface from catalyst preparation did not significantly affect the concentration of CH<sub>3</sub>O that formed.

Note in Fig. 12 that the  $CH<sub>4</sub>$  amount is essentially saturated after 15 min (or less) exposure, but unreacted CO is only saturated after 60 min exposure. The dimethyl ether signal does not appear to reach saturation, even at 90 min, but dimethyl ether represents a small fraction of the total amount of products. The methanol signal decreased at longer times while dimethyl ether increased, as if the additional adsorption time allowed adsorbed methanol to decompose to dimethyl ether.

### *Isotope Labeling*

In an attempt to study the process that occurred during TPR and to distinguish CO that was originally adsorbed on Pd from CH<sub>3</sub>O adsorbed on  $\text{Al}_2\text{O}_3$ , isotopically labeled CO was used. The procedure for these experiments was as follows:

(1) <sup>12</sup>CO was adsorbed in H<sub>2</sub> flow at 385 K.

(2) The catalyst was then exposed to  ${}^{13}CO$ at 300 K in  $H<sub>2</sub>$  flow for 20 min.

(3) TPR was carried out and  ${}^{13}CH_4$ ,  ${}^{12}CH_4$ , <sup>13</sup>CO, and <sup>12</sup>CO were observed.

The objective of Step (1) was to form  ${}^{12}CH<sub>3</sub>O$  on the Al<sub>2</sub>O<sub>3</sub> surface, and in a series of three experiments a range of  ${}^{12}CH_3O$  coverages was used. Simultaneous with  ${}^{12}CH_3O$ formation,  $^{12}CO$  adsorbed on Pd. The pojective of Step (2) was to exchange only the  $^{12}CO$  on Pd with  $^{13}CO$ .

Thus, at the start of the TPR experiment, only <sup>12</sup>CH<sub>3</sub>O was adsorbed on  $Al_2O_3$  and mostly 13CO was adsorbed on Pd. Several results confirmed that this was the starting condition:

• In a separate experiment, <sup>13</sup>CO was adsorbed at 300 K for 15 min in He flow. The catalyst was then exposed to  $^{12}CO$  in He flow at 300 K for 15 min. A subsequent TPR experiment yielded mostly  ${}^{12}CH_4$ . The <sup>13</sup>CH<sub>4</sub> signal was only 15% of the <sup>12</sup>CH<sub>4</sub> signal, and had the same shape. Similarly, a small amount of unreacted <sup>12</sup>CO was detected, and the 13CO signal was only 15% of the  $^{12}CO$  signal. That is, the majority of the <sup>13</sup>CO, which was adsorbed on Pd, exchanged with gas phase  ${}^{12}CO$  at 300 K in 15 min.

• The  $^{12}CH<sub>3</sub>O$ , which formed in Step (1), is not expected to exchange with gas phase  ${}^{13}CO$  in Step (2) because  ${}^{12}CH_3O$  on the  $Al_2O_3$  surface of  $Ni/Al_2O_3$  did not exchange with 13CO *(26).* 

• The combined amounts of <sup>13</sup>CO and  ${}^{13}CH_4$  measured in each of the TPR experiments described below was approximately the same as that observed when CO was adsorbed only at 300 K. That is, even when <sup>12</sup>CH<sub>3</sub>O was present on  $Al_2O_3$ , <sup>13</sup>CO was only adsorbed (by exchange) on the Pd surface.

When no adsorption was carried out at 385 K (Step (1)), and <sup>13</sup>CO (or <sup>12</sup>CO) was adsorbed on  $Pd/Al_2O_3$  at 300 K, 95% of the CO reacted to  $CH<sub>4</sub>$  during TPR (Figs. 4(a) and  $5(a)$ ). However, as the amount of  ${}^{12}CH<sub>3</sub>O$  increased (by longer  ${}^{12}CO$  exposure

**TABLE l** 

**13CO Hydrogenation during TPR for Isotope Labeling Experiments** 

<sup>12</sup> CO adsorption conditions	Percentage of <sup>13</sup> CO hydrogenated to <sup>13</sup> CH <sub>4</sub>
No <sup>12</sup> CO adsorption (Fig. 4a, 5a)	95
20 min at 385 K in ambient H <sub>2</sub> (Fig. 13)	60
30 min at 385 K in ambient H <sub>2</sub>	42
60 min at 385 K in 2.6 atm H <sub>2</sub> (Fig. 14)	14

at 385 K or higher  $H_2$  pressures in Step  $(1)$ ) the percentage of <sup>13</sup>CO that was hydroge**nated to 13CH4 decreased dramatically, as shown in Table 1.** 

**Figure 13 shows the TPR spectra obtained when 12CO was adsorbed for 20 min at 385**  K in Step (1). The  ${}^{12}CH_4$  and  ${}^{12}CO$  result **from the adsorbed 12CH30. The 13cn4 signal**  was similar in shape to the  ${}^{12}CH_4$  signal. **Only 60% of the adsorbed 13CO was hydro**genated to  $^{13}CH_4$ . Some of the  $^{13}CO$  de**sorbed below 475 K, as observed in Fig. 5(a). However, the majority of the unre**acted <sup>13</sup>CO desorbed above 475 K; the rate



**Flo. 13. TPR spectra for 12CO adsorption at 385 K in**  ambient pressure  $H_2$  for 20 min followed by 20 min of <sup>13</sup>CO exposure in ambient pressure  $H_2$  at 300 K: (a) <sup>12</sup>CH<sub>4</sub> and <sup>13</sup>CH<sub>4</sub>, (b) <sup>12</sup>CO and <sup>13</sup>CO.



**Fro. 14. TPR spectra for 12CO adsorption at** 385 K **in**  2.6 atm H<sub>2</sub> for 60 min followed by 20 min of  $\rm ^{13}CO$ exposure in ambient pressure  $H_2$  at 300 K: (a) <sup>12</sup>CH<sub>4</sub> **and I3CH4, b) 12CO and 13CO.** 

**of 13CO desorption above 475 K in Fig. 13 is 65 times that observed in Fig. 5(a). Note that 13CO desorbed with a lower peak temperature than 12CO.** 

As the <sup>12</sup>CH<sub>3</sub>O coverage increased, the changes in the <sup>13</sup>CO desorption and hydro**genation continued. As shown in Fig. 14, at close to saturation 12CH30 coverage, only 14% of the adsorbed 13CO was hydrogenated to 13CH4. Moreover, 13CO desorbed at a significantly lower temperature than <sup>12</sup>CO. The** <sup>13</sup>CO peak temperature is 495 K and that of **12CO is 526 K. Figure 14 also shows that CH30 on AI203 is more likely to be hydrogenated than CO on Pd.** 

**The large changes in the desorption and hydrogenation properties of 13CO adsorbed on Pd are the result of the spillover processes that take place during TPR. At low initial 12CH30 coverages, 13CO, which was originally on Pd, formed <sup>13</sup>CH<sub>3</sub>O on Al<sub>2</sub>O<sub>3</sub>** by spillover during TPR, and this <sup>13</sup>CH<sub>3</sub>O **was subsequently hydrogenated almost**  completely to  ${}^{13}CH_4$ . At high initial  ${}^{12}CH_3O$ **coverages, the methanation probability de-**  creased, as shown. Thus, the majority of the  ${}^{13}CO$ , which was adsorbed on Pd, may have desorbed directly from Pd. As seen in Fig. 9, as the CH<sub>3</sub>O coverage increased, CO desorbed at progressively lower temperatures. The higher  $CH<sub>3</sub>O$  coverage may have provided a driving force for  ${}^{12}CH_3O$  to diffuse back to Pd at high temperatures and this could have increased the rate of 13CO deposition from the Pd *(16).* Figures 13 and 14 show that the CO adsorbed on Pd preferentially desorbed at lower temperatures.

Thus, the TPR experiments with isotopes show that CO is hydrogenated on  $Pd/Al_2O_3$ by first spilling over onto the  $Al_2O_3$  to form  $CH<sub>3</sub>O$ . The  $CH<sub>3</sub>O$  then hydrogenates faster than CO on Pd.

#### *Mechanism*

A mechanism in which CO is not dissociated to carbon and oxygen but the CO molecule is first partially hydrogenated was proposed by Mori *et al.* (27, 28) for  $Pd/Al_2O_3$ . They proposed that a H<sub>2</sub>COH intermediate was formed on the Pd surface. A process in which CO is partially hydrogenated before dissociating is consistent with our observation that  $CH<sub>3</sub>O$  is hydrogenated faster than CO on Pd. This may explain the higher methanation activity of  $Pd/Al<sub>2</sub>O<sub>3</sub>$  relative to  $Pd/SiO_2$ , since CH<sub>3</sub>O forms on  $Al_2O_3$  surfaces from  $CO + H<sub>2</sub>$  but not on  $SiO<sub>2</sub>$  surfaces for Pd catalysts *(11).* Vannice *et al. (29)* proposed that the support facilitated bond rupture and was directly involved in the methanation process. They also concluded that the support is directly involved in methanol synthesis.

The hydrogenation of  $CH<sub>3</sub>O$ , which is adsorbed on the support, may be the dominant reaction for methanation on  $Pd/Al_2O_3$ . This may not be the pathway for methanol formation, however, since the rate of methanol formation was similar for  $Pd/SiO<sub>2</sub>$  and  $Pd/$  $\text{Al}_2\text{O}_3$  (17). Similarly, Pd/La<sub>2</sub>O<sub>3</sub> is more active for methanation than  $Pd/SiO<sub>2</sub>$ , and the rate expressions for methanation on the two catalysts are different *(30).* Also, following CO adsorption at 300 K, the peak temperature during TPR was 525 K for Pd/La<sub>2</sub>O<sub>3</sub> and 635 K for Pd/SiO<sub>2</sub> (12). While only 43% of adsorbed CO on  $Pd/SiO<sub>2</sub>$  was hydrogenated to  $CH_4$ , 94% of CO on Pd/La<sub>2</sub>O<sub>3</sub> was hydrogenated  $(12)$ . That is, Pd/La<sub>2</sub>O<sub>3</sub> and  $Pd/Al<sub>2</sub>O<sub>3</sub>$  exhibited similar behavior, and CH30 hydrogenation may be responsible for the higher activity of  $Pd/La_2O_3$ . However, the rate expressions for methanol synthesis are similar for  $Pd/SiO<sub>2</sub>$  and  $Pd/La<sub>2</sub>O<sub>3</sub>$ , which indicates the mechanism for methanol synthesis is the same on these catalysts *(30).* 

#### **CONCLUSIONS**

On  $Pd/Al_2O_3$ , CH<sub>3</sub>O species readily form on the  $AI_2O_3$  surface from CO and H<sub>2</sub> in an activated process. At low coverages, CH<sub>3</sub>O is readily hydrogenated to  $CH<sub>4</sub>$ , but at high  $CH<sub>3</sub>O$  coverages decomposition and desorption compete with methanation. The  $CH<sub>3</sub>O$  coverage increases with  $H<sub>2</sub>$  pressure and exposure time, and the saturation coverage on  $Al_2O_3$  is 360  $\mu$ mol/g  $Al_2O_3$ . Both  $CH<sub>3</sub>OH$  and  $CH<sub>3</sub>OCH<sub>3</sub>$  are detected during TPR following CO adsorption at higher  $H<sub>2</sub>$ pressures. Isotope studies demonstrated that CO adsorbed on Pd spills over onto  $Al_2O_3$ , and the CH<sub>3</sub>O on  $Al_2O_3$  is hydrogenated at a faster rate than CO on Pd. Thus, the  $CH<sub>3</sub>O$  species on  $Pd/Al<sub>2</sub>O<sub>3</sub>$  hydrogenates at a much faster rate than CO on Pd/  $SiO<sub>2</sub>$ , and it is possible that CH<sub>3</sub>O hydrogenation is responsible for the higher methanation activity observed in steady-state experiments on  $Pd/Al_2O_3$ .

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#### REFERENCES

1. Kester, K. B., and Falconer, *J. L., J. Catal.* 89, 380 (1984).

- 2. Glugla, P. G., Bailey, K. M., and Falconer, J. L., *J. Phys. Chem. 92,* 4474 (1988).
- 3. Bailey, K. M., Chai, G-Y., and Falconer, J. L., *in*  "Proceedings, 9th International Congress on Catalysis, Calgary, 1988" (M. J. Phillips and M. Ternan, Eds.), Vol. 3, p. 1090. Chem. Institute of Canada, Ottawa, 1988.
- 4. Sen, B., and Falconer, *J. L., J. Catal.* 117, 404 (1989).
- 5. Sen, B., and Falconer, *J. L., J. Catal.* 122, 68 (1990).
- 6. Sen, B., and Falconer, *J. L., J. Catal.* 113, 444 (1988).
- 7. Robbins, J. L., and Marucchi-Soos, E., *J. Phys. Chem.* 93, 2885 (1989).
- 8. Flesner, R. L., and Falconer, J. L., in preparation.
- 9. Mao, T-F., and Falconer, *J. L., J. Catal. 123, 443*  (1990).
- *I0.* Vannice, M. A., and Garten, R. L., *Ind. Eng. Chem. Prod. Res. Dev.* 18, 186 (1979).
- *11.* Palazov, A., Kadinov, G., Bonev, Ch., and Shopov, *D., J. Catal.* 74, 44 (1982).
- *12.* Rieck, J. S., and Bell, *A. T., J. Catal.* 96, 88 (1985).
- *13.* Leary, K. J., Michaeis, J. N., and Stacy, A. M., *Langmuir* 4, 1251 (1988).
- *14.* Paryjczak, T., Farbotko, J. M., and Zielinski, *P. A., Pol. J. Chem.* 62, 567 (1988).
- *15.* Kokh, I. G., Vozdvizhenskii, V. F., and Babenkova, L. V., *Russ. J. Phys. Chem. Engl. Transl.*  63, 539 (1989).
- *16.* Guo, X., Xu, Y., Zhai, R., Zhu, K., and Huang, *J., Pure Appl. Chem. 60,* 1307 (1988).
- *17.* Poutsma, M. L., Elek, L. F., Ibarbia, P. A., Risch, A. P., and Rabo, *J. A., J. Catal.* 52, 157 (1978).
- *18.* Falconer, J. L., and Schwarz, J. A., *Catal. Rev. Sci. Eng.* 25, 141 (1983).
- *19.* Miura, H., Hondou, H. Sugiyama, K., Matsuda, T. and Gonzales, R. D., *in* "Proceedings 9th International Congress on Catalysis, Calgary, 1988" (M. J. Phillips and M. Ternan, Eds.) Vol. 3, p. 1307. Chem. Institute of Canada, Ottawa, 1988.
- *20.* Glugla, P. G., Bailey, K. M., and Falconer, J. L., *J. Catal.* 115, 24 (1989).
- *21.* Ichikawa, S., Poppa, H., and Boudart, *M., J. CataL* 91, 1 (1985).
- *22.* Sen, B., Falconer, J. L., Mao, T-F., Yu, M., and Flesner, *R. L., J. Catal.* 127, 465 (1990).
- *23.* Montagne, X., Boulet, R., Freund, E., and Lavalley, J. C., *in* "Structure and Reactivity of Surfaces" (C. Morterra, A. Zecchina, and G. Costa, Eds), p. 695. Elsevier, Amsterdam, 1989.
- *24.* Zagli, E., Ph.D. Thesis, University of Colorado, Boulder, 1981.
- *25.* Fujimoto, K., Asami, K., Shikada, T., and Tominaga, H., *Chem. Lett. 12,* 2051 (t984),
- *26.* Chen, B., Falconer, J. L. and Chang, *L., J. Catal.*  127, 732 (1991).
- 27. Niizuma, H., Mori, T., Miyamoto, A., Hattori, T., Masuda, H., Imai, H., and Murakami, Y., J. *Chem. Soc. Chem. Commun.* 10, 562 (1982).
- 28. Mori, T., Masuda, H., Imai, H., Miyamoto, A., Niizuma, H., Hatori, T., and Murakami, Y., *Pan-Pac. Synfuels Conf.* 1, I52, (1982).
- *29.* Vannice, M. A., Sudhakar, and Freeman, M., J. *Catal.* 117, 97 (1987).
- *30.* Hicks, R. F., and Bell, *A. T., J. Catal.* 91, 104 (1985).